DOCKET NO.

PLAINTIFF

07CV818 (AKH)

ANVIK CORPORATION

PATENT OR

TRADEMARK NO.

TO:

Mail Stop 8 Director of the U.S. Patent and Trademark Office P.O. Box 1450 Alexandria, VA 22313-1450

DATE FILED

2/2/2007

DATE OF PATENT

OR TRADEMARK

REPORT ON THE FILING OR DETERMINATION OF AN ACTION REGARDING A PATENT OR TRADEMARK

Southern District of New York

SAMSUNG ELECTRONICS AMERICA, ET AL.

HOLDER OF PATENT OR TRADEMARK

In Compliance with 35 U.S.C. § 290 and/or 15 U.S.C. § 1116 you are hereby advised that a court action has been on the following Southern District of New York filed in the U.S. District Court ☐ Trademarks or ☑ Patents. (☐ the patent action involves 35 U.S.C. § 292.):

U.S. DISTRICT COURT

DEFENDANT

See Attached Sheet

See Attached Sheet		See Attached Sheet		
2 4,924, 257				
3 5,285,236				
45,291,240				
5				
	in the above—entitled case, the fo	llowing patent(s)/ trademar	k(s) have been includ	ed:
DATE INCLUDED	INCLUDED BY		☐ Cross Bill	Other Pleading
PATENT OR TRADEMARK NO.	DATE OF PATENT OR TRADEMARK	HOLDI	ER OF PATENT OR	FRADEMARK
I See Attached Sheet		See Attached Shee	<u> </u>	
2				
3				
4				
5				
In the abov	e-entitled case, the following de	ecision has been rendered o	r judgement issued:	
DECISION/JUDGEMENT				
COPY ATTACHED: JUI	OGMENT			
			115	
CLERK	(BY)	DEPUTY CLERK		DATE
Ruby J. Krajick		- JAV	- Ca	- 4/6/2012
	action, mail this copy to Directo ent adding patent(s), mail this c	r Copy 3—Upon termin	nation of action, mail	this copy to Director

UNITED STATES DISTRICT COURT SOUTHERN DISTRICT OF NEW YORK

USDC SDNY
DOCUMENT
ELECTRONICALLY FILED
SOC #
DATE FILED: 4/12

ANVIK CORPORATION,

Plaintiff,

NIKON PRECISION, INC., et al.,

LG.PHILIPS LCD CO., LTD., et al.,

SAMSUNG ELECTRONICS AMERICA, INC., et al.,

CHI MEI OPTOELECTRONICS, et al.,

AU OPTRONICS CORP., et al.,

SHARP CORP., et al.,

INNOLUX DISPLAY CORP.,

HANNSTAR DISPLAY CORP.,

AFPD PTE LTD., and IPS ALPHA TECHNOLOGY, LTD, et al.

Defendants.

Civ. No. 05-7891 (AKH)

Civ. No. 07-0816 (AKH)

Civ. No. 07-0818 (AKH)

Civ. No. 07-0821 (AKH)

Civ. No. 07-0822 (AKH)

Civ. No. 07-0825 (AKH)

Civ. No. 07-0826 (AKH)

Civ. No. 07-0827 (AKH)

Civ. No. 07-0828 (AKH) Civ. No. 08-4036 (AKH)

x

JUDGMENT

Upon the Court's Order of April 4. 2012 (the "Order"), it is hereby ordered that the above-captioned actions are dismissed upon the following terms:

 Claims 17 and 18 of U.S. Patent No. 4,924,257 are declared invalid for failure to comply with the requirement that "[t]he specification... shall set forth the best mode contemplated by the inventor of carrying out his invention." 35 U.S.C. § 112.

- Claims 23 and 25 of U.S. Patent 5,285,236 are declared invalid for failure to
 comply with the requirement that "[t]he specification . . . shall set forth the best mode
 contemplated by the inventor of carrying out his invention." 35 U.S.C. § 112.
- Claim 25 of U.S. Patent 5,291,240 is declared invalid for failure to comply with
 the requirement that "[1]he specification . . . shall set forth the best mode contemplated by the
 inventor of carrying out his invention." 35 U.S.C. § 112.
- Plaintiff's Complaint or Amended Complaint, as the case may be, in each of the above-captioned actions is dismissed with prejudice.
 - 5. This is without prejudice to Plaintiff's right to appeal.
- Defendants' Counterclaims, other than those asserting invalidity of U.S. Patents
 Nos. 4,924,257, 5,285,236, and 5,291,240 in each of the above-captioned actions, are dismissed without prejudice as moot.

April 5_,2012

CLERK OF COURT

United States Patent [19]

[11] Patent Number:

4,924,257 May 8, 1990

Jain				
[54]	SCAN ANI	RE	PEAT HIGH RESOLUTION LITHOGRAPHY SYSTEM	
[76]	Inventor:	Kan Bris	tilal Jain, 18 Algonquian Trail, arcliff Manor, N.Y. 10510	
(21)	Appl. No.:	253	717	
[22]	Filed:		. 5, 1988	
[51] [52]	U.S. Cl			
[58]	Field of Se 356/400	arch , 401	; 250/548, 442.1, 205, 491.1, 492.2, 492.3	
[56]		Re	ferences Cited	
	U.S.	PAT	ENT DOCUMENTS	
	4,701,608 10/ 4,748,477 5/ 4,749,867 6/ 4,825,086 4/	1988	Isohata et al	
Acri	nary Examino stant Examin rney, Agent,	er-	., T. Hix D. Rutledge rmCarl Kling	
[57]			ABSTRACT	

This scan and repeat lithography system has high resolution capability, large effective image field size, and

high substrate exposure speed, and comprises: (a) a

substrate stage capable of scanning a substrate in one dimension and, when not scanning in said dimension, capable of moving laterally in a direction perpendicular to the scan direction so as to position the substrate for another scan; the substrate stage exposing the full substrate by breaking up the substrate area into parallel strips, and exposing each of the strips by scanning the length of the strip across a fixed illumination region; (b) a mask stage capable of scanning in the same direction as, and synchronized with, the substrate stage, at a speed faster than the substrate stage scanning speed by a certain ratio M; (c) an illumination subsystem having an effective source plane in the shape of a polygon, and capable of uniformly illuminating a polygon-shaped region on the mask; (d) a projection subsystem having an object-to-image reduction ratio M, and having a polygon-shaped image field of an area smaller than the desired effective image field size of the lithography system; and (e) provision of complementary exposures in an overlap region between the areas exposed by adjacent scans in such a way that a seam in the exposure dose distribution received on the substrate is absent between the scans, and such that the exposure dose delivered across the entire substance is uniform.

22 Claims, 5 Drawing Sheets

